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Applicant: TEKTRONIX INC

Inventor: HINCHLIFFE ROBERT D

KEPHART DONALD E

BATH FOR ELECTROPHORETIC DEPOSITION AND DEPOSITION METHOD

**Abstract:**

**PROBLEM TO BE SOLVED:** To provide the bath for electrophoretic deposition which is suitable for the manufacture of an electrode structure capable of reducing a current supplied to plasma while the sputtering of an electrode is reduced by allowing the bath for electrophoretic deposition to contain magnesium nitrate of specific concn.

**SOLUTION:** The current supplied to the plasma of a PALC display panel depends upon the concn. of magnesium nitrate in the bath for electrophoretic deposition and the concn. of the magnesium nitrate for forming a sufficient coating of LaB

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